

ABSTRACT

MANUFACTURING METHOD FOR ELECTRONIC SUBSTRATE,
MANUFACTURING METHOD FOR ELECTRO-OPTICAL DEVICE, AND
5 MANUFACTURING METHOD FOR ELECTRONIC DEVICE

A manufacturing method for an electronic substrate, includes: preparing a substrate and a mask having a predetermined region; forming a wiring pattern on the substrate; forming an aperture portion in the predetermined region of the mask; affixing the mask on the
10 substrate; and removing at least a part of the wiring pattern through the aperture portion of the mask thereby forming the electronic element on the substrate.

Fig. 7C